

Re-entrant Negative Coulomb Drag in a 1D Quantum Circuit

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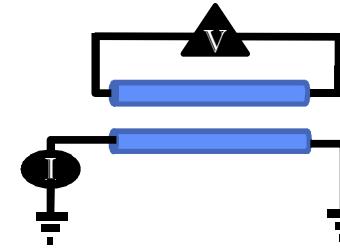
Motivation

Goal : Study electron interactions in 1 dimensional systems

- Address multiple 1D subbands regime
- Electron hole asymmetry
- Luttinger liquid theory

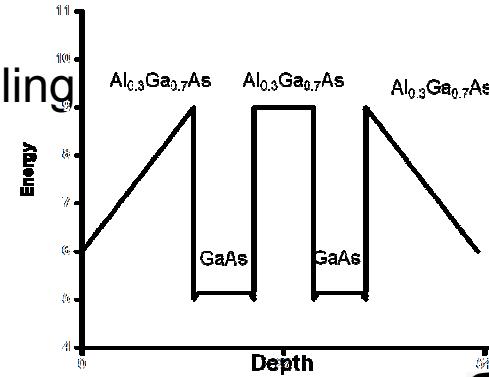
Tool : Coulomb Drag measurement

- Direct probe of electron-electron interactions



How : Independent and vertically-coupled quantum wires

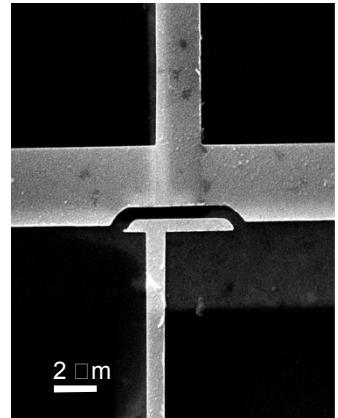
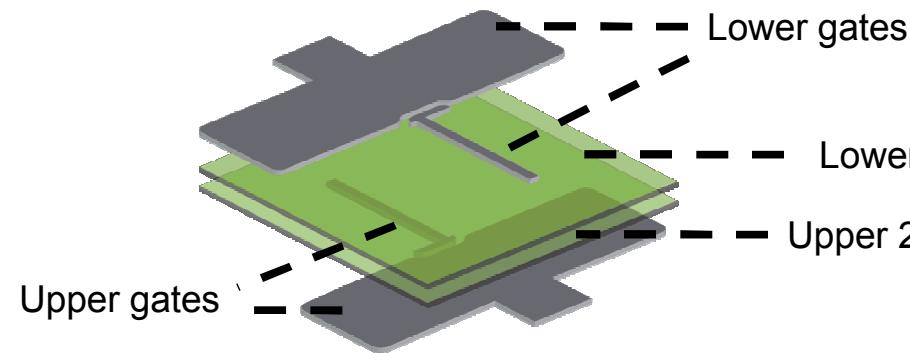
- Direct control of the 1D subband occupancy in each wire independently
- Smaller inter-wire separation without tunnelling
 - Stronger drag signal
 - Stronger coupling between the wires
 - Smaller influence of phonon drag



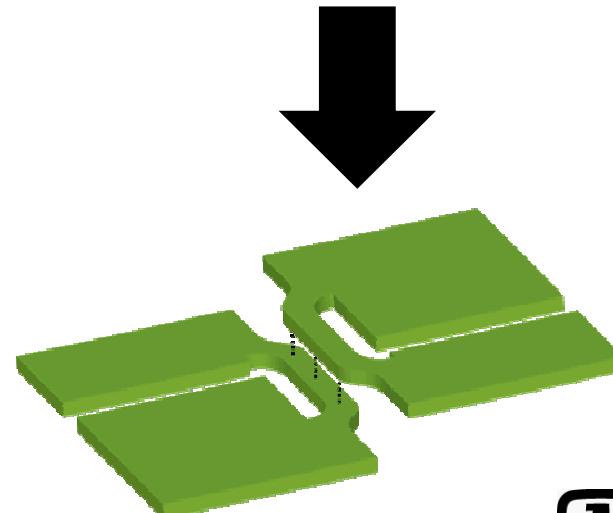
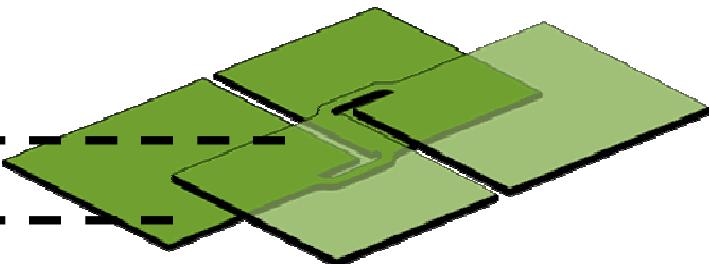
Sample design and fabrication

- Use 18 nm wide double quantum well heterostructures with a 15 nm barrier.
- Fabricated through an Epoxy-Bound And Stopped-Etch technique*
- Fabricate 4.2 μm long vertically-coupled quantum wires

Gates design



Gates activated

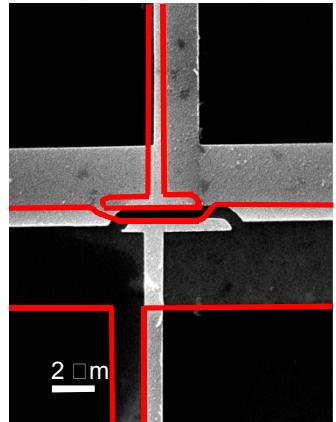
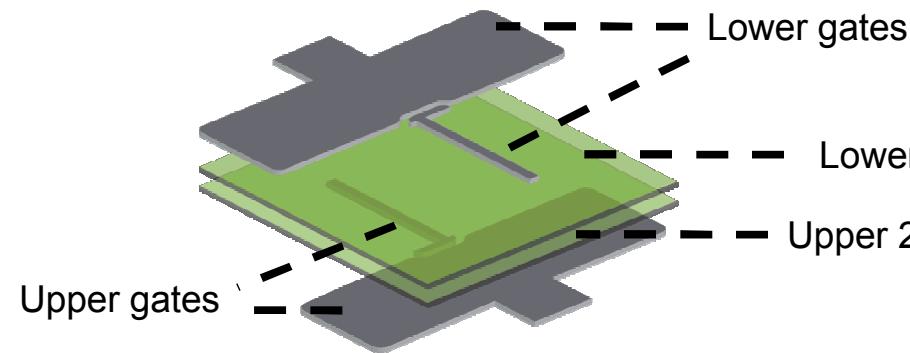


* M. V. Weckwerth et al. Superlatt. Microstruct. 20, 561 (1996).

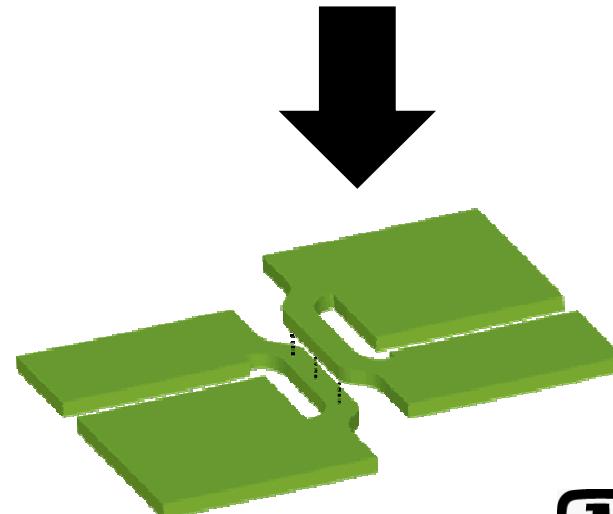
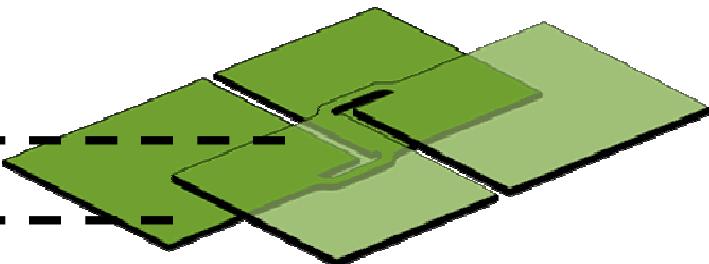
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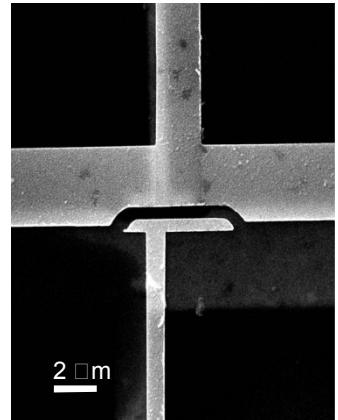
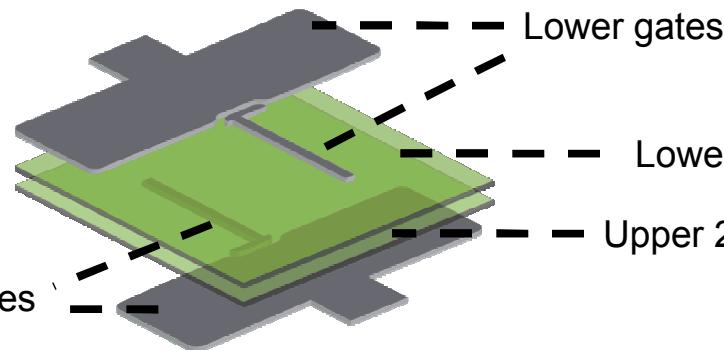
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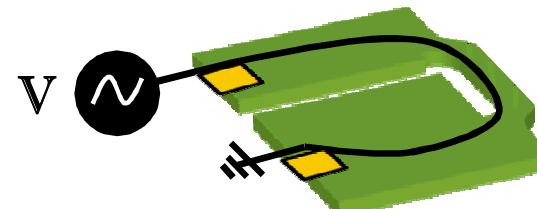
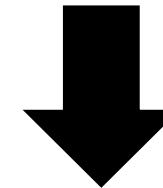
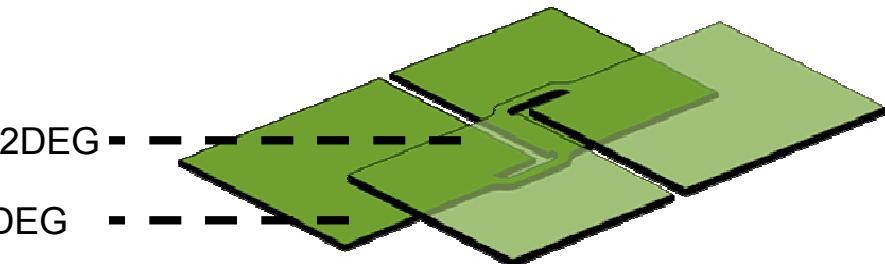
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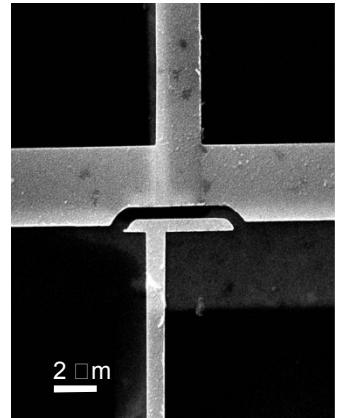
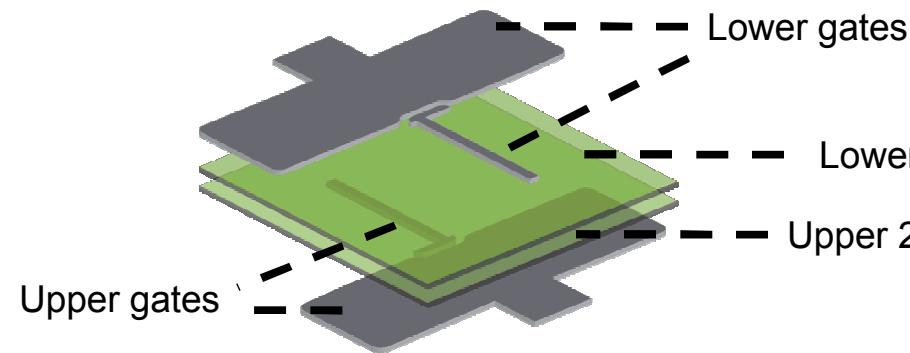
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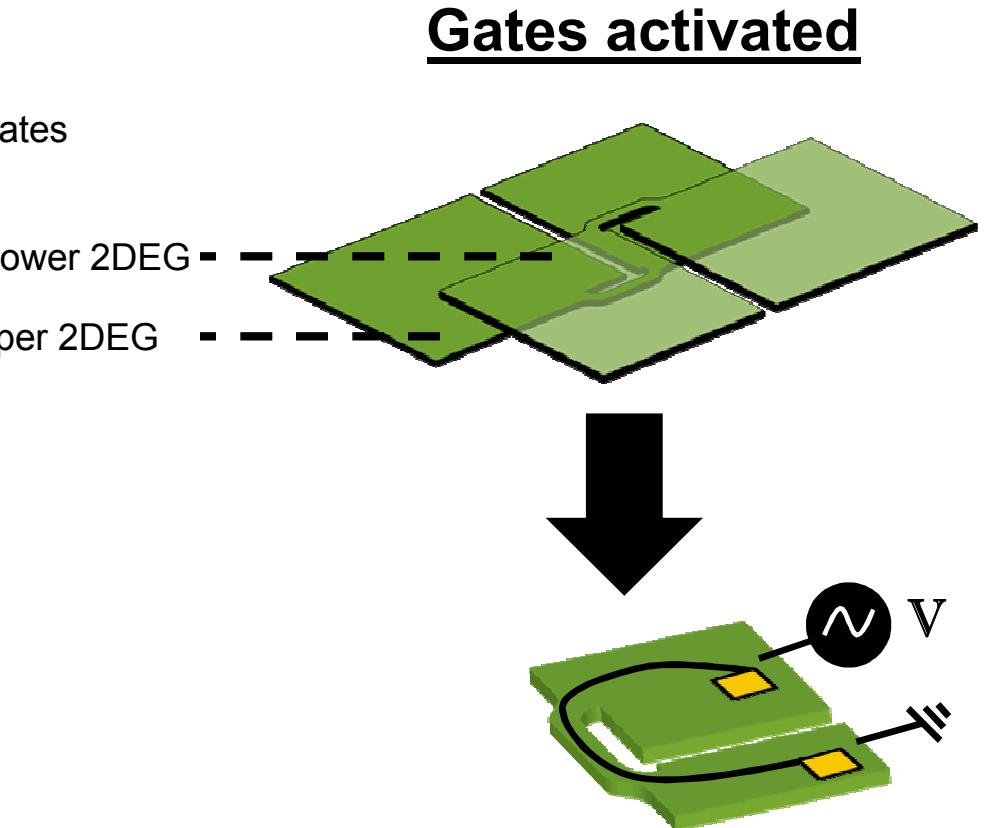
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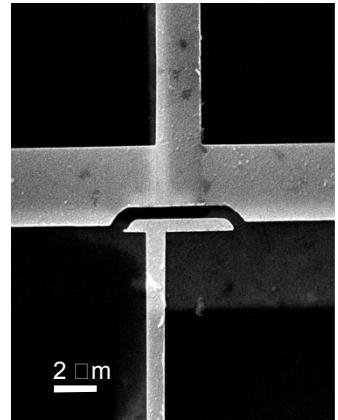
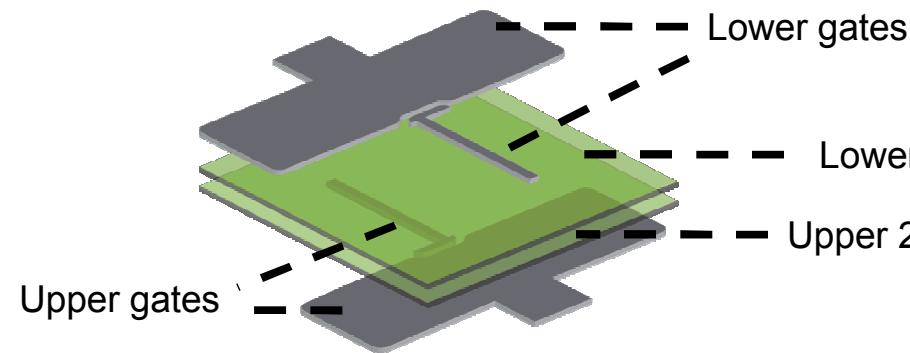
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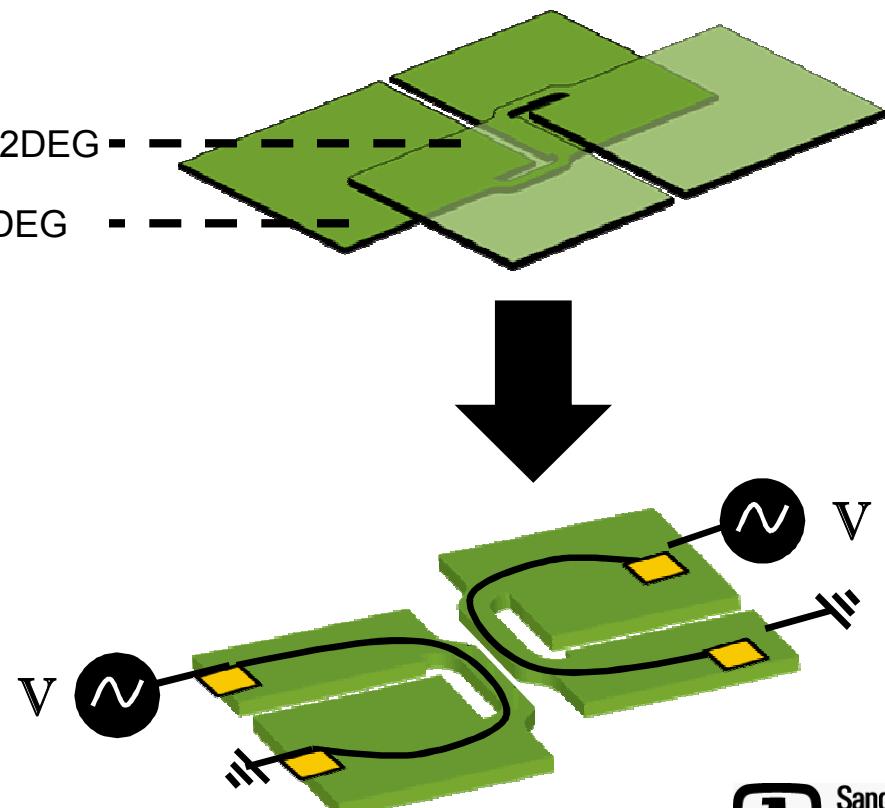
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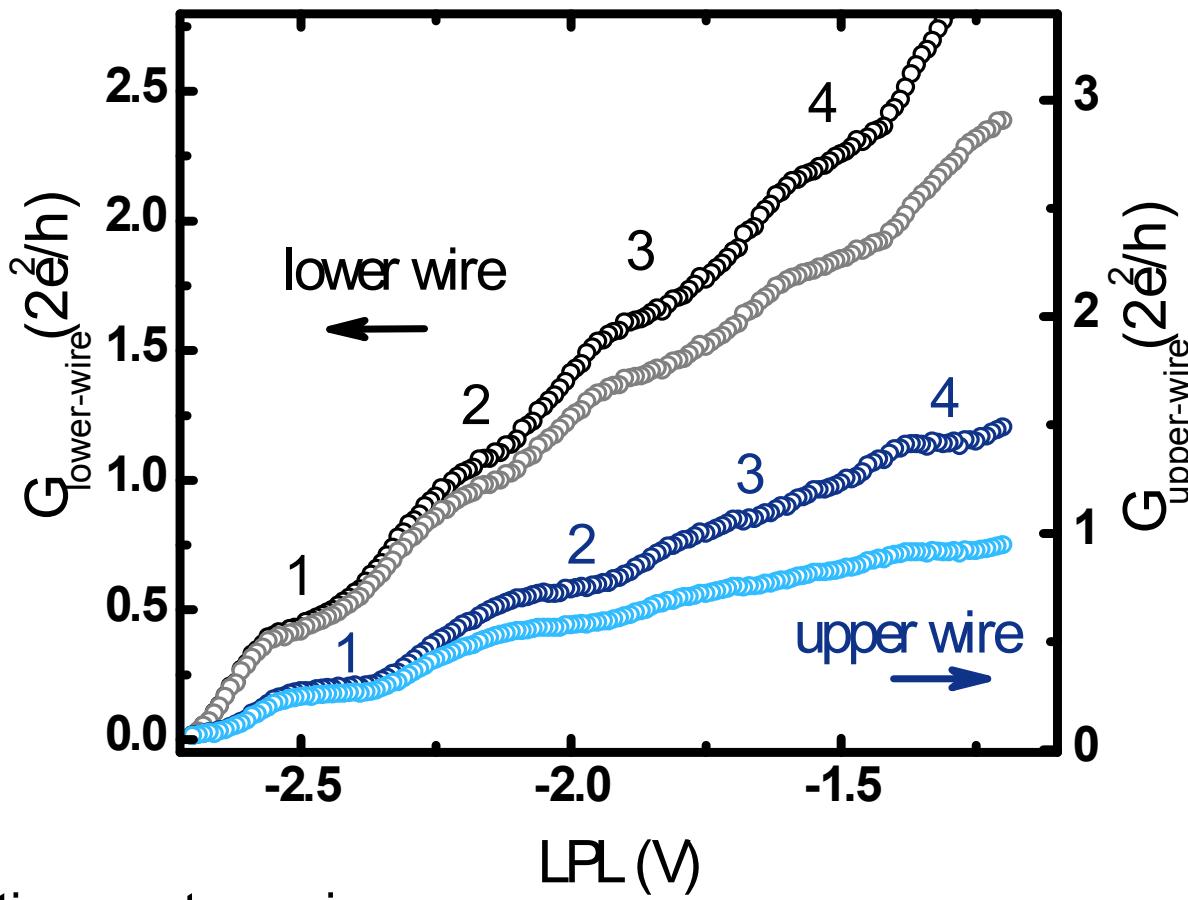


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Wires characterization

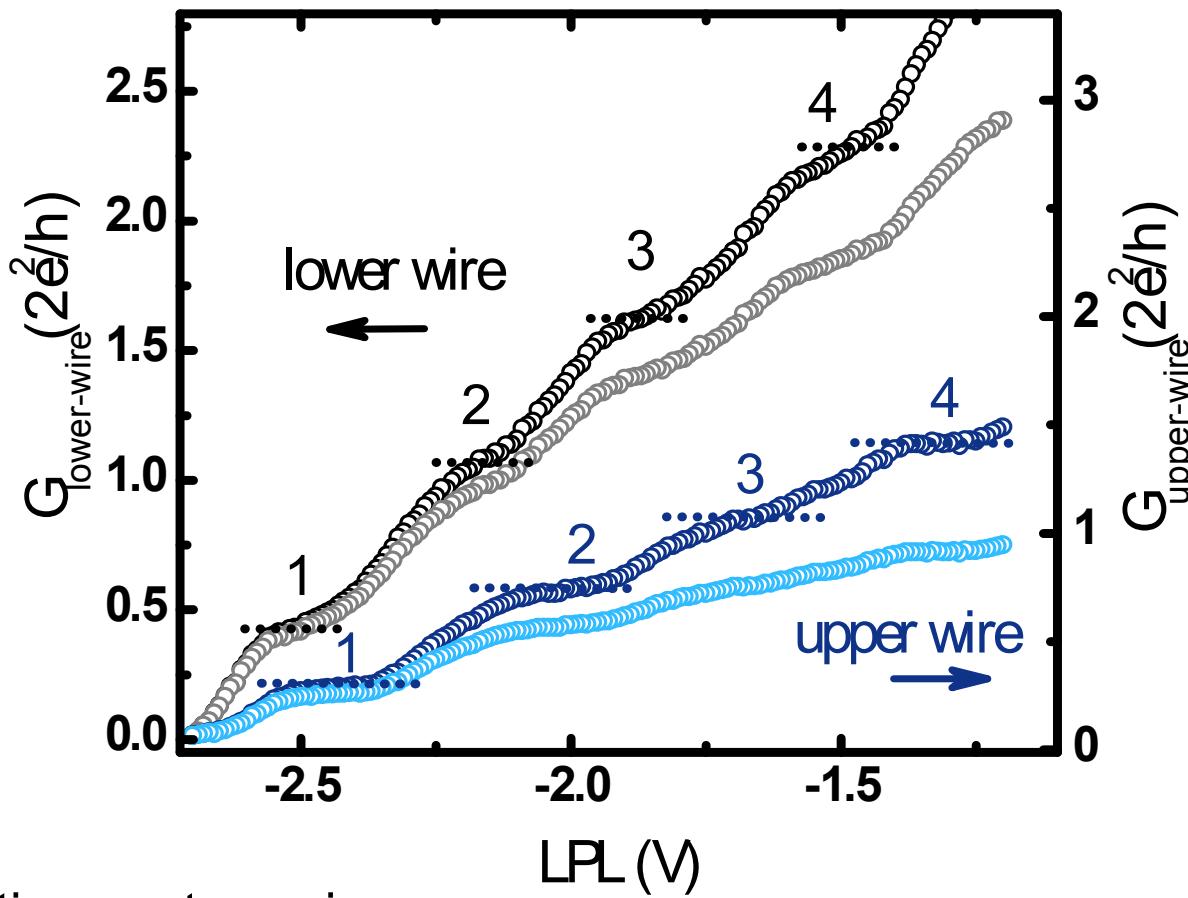
Fixed UPL = -0.23V



- Non-ballistic quantum wires
 - After subtracting a series resistance, even plateau-like features spa

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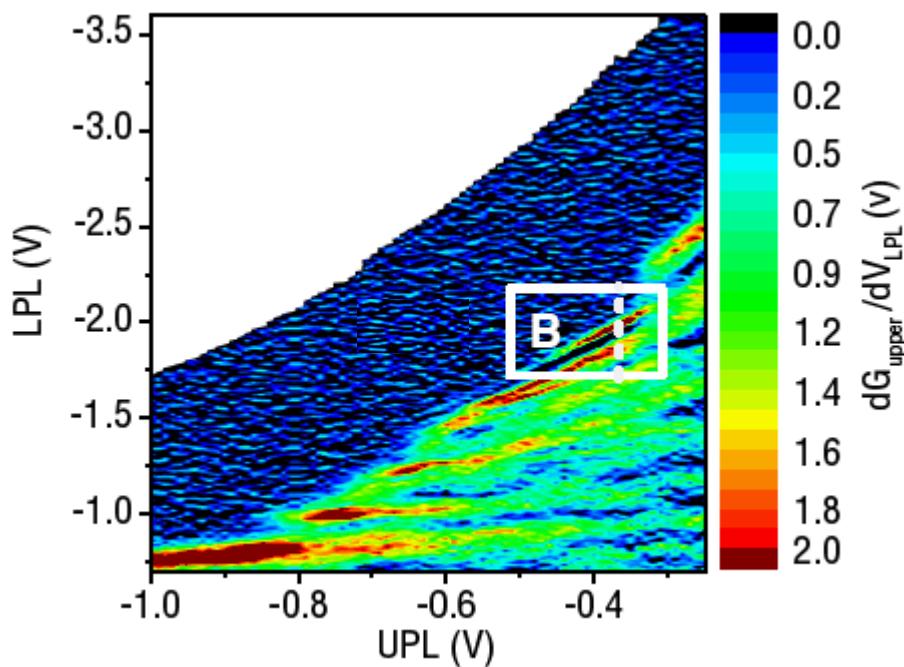


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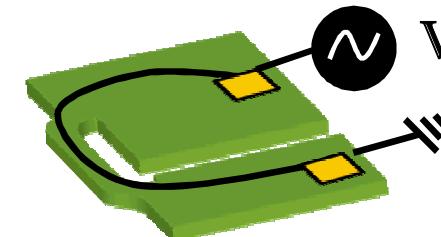
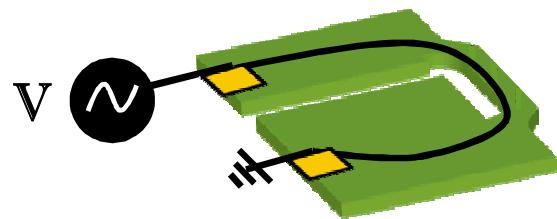
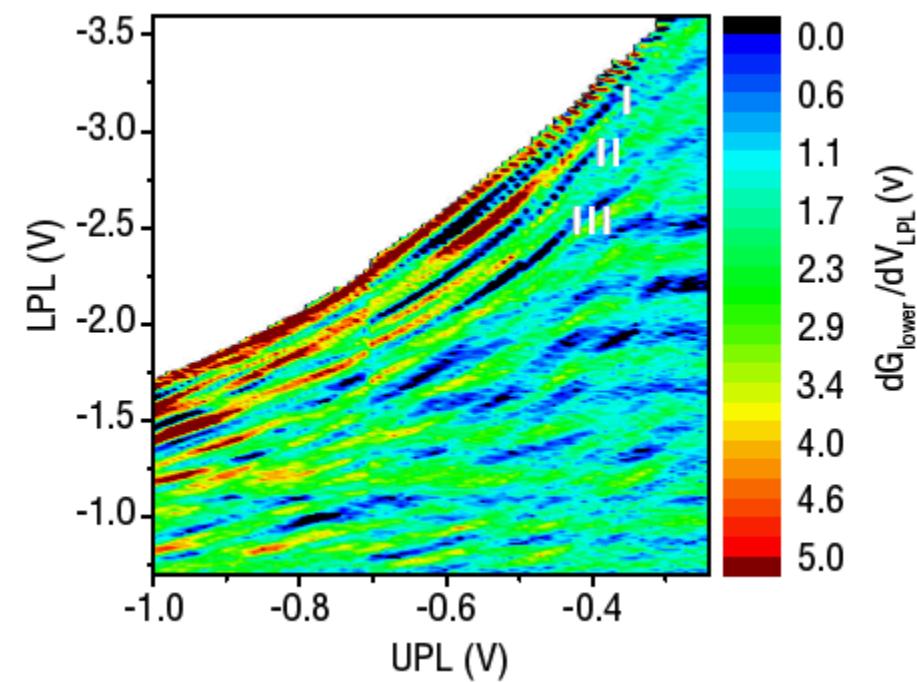
Wires characterization

Tracking of the 1D subbands over a large range of gates voltage

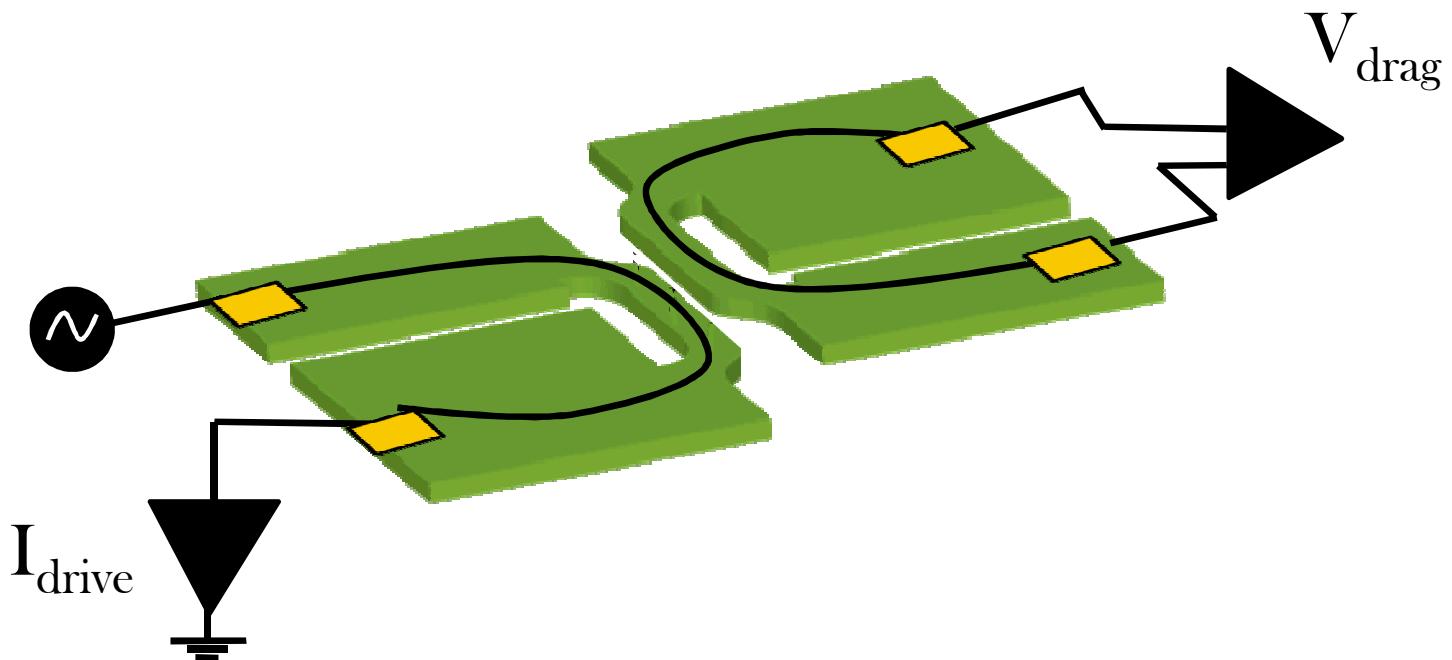
Upper wire derivative



Lower wire derivative



General Coulomb drag measurements

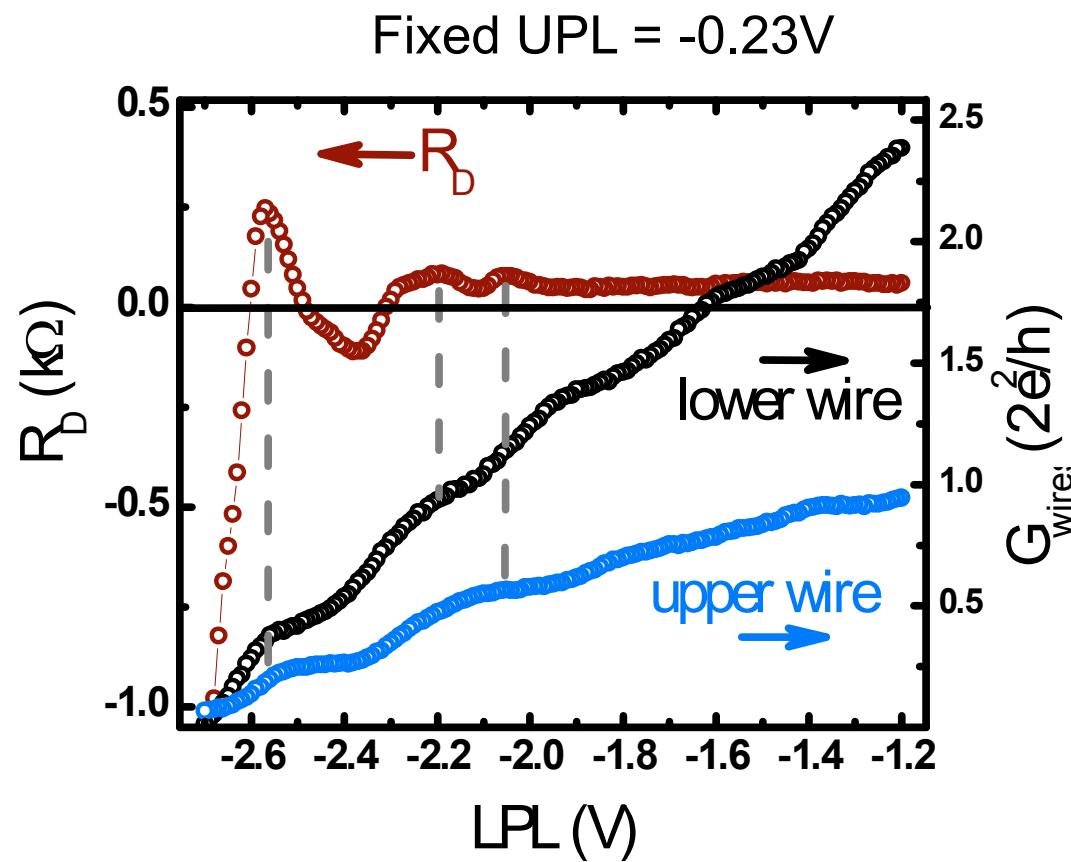


Measured quantity : transresistance

$$R_D = - \frac{V_{\text{drag}}}{I_{\text{drive}}}$$

Coulomb drag results

- Peaks in the drag signal as 1D subbands gets depleted.
(Previously observed by Debray *et. al.*¹)
- Low-density negative drag observed when $N_{\text{wires}} < 1$
(Previously observed by Yamamoto *et. al.*²)
- Re-entrant negative drag at the 1st plateau-like feature of the drag wire
 - Never observed previously !

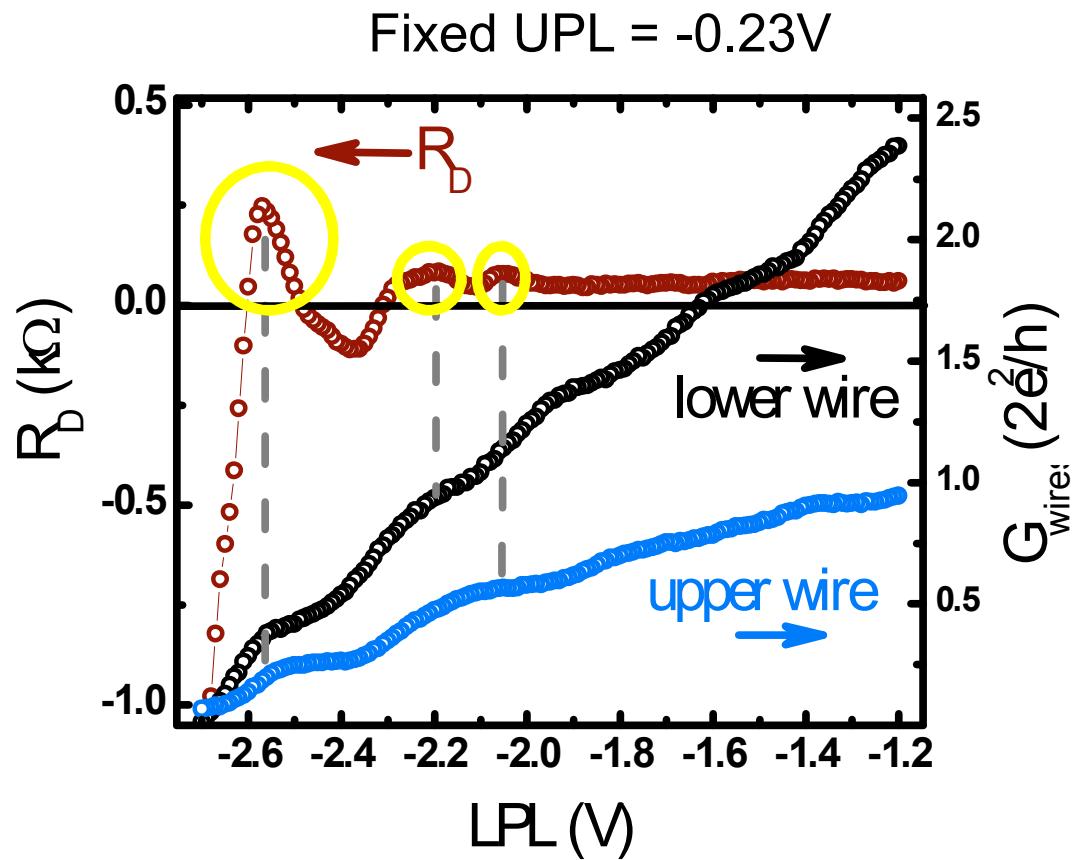


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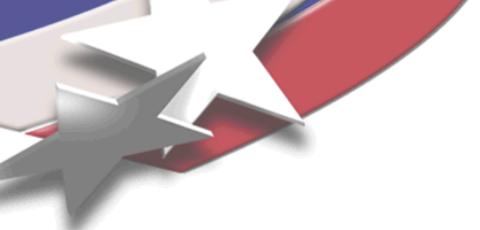


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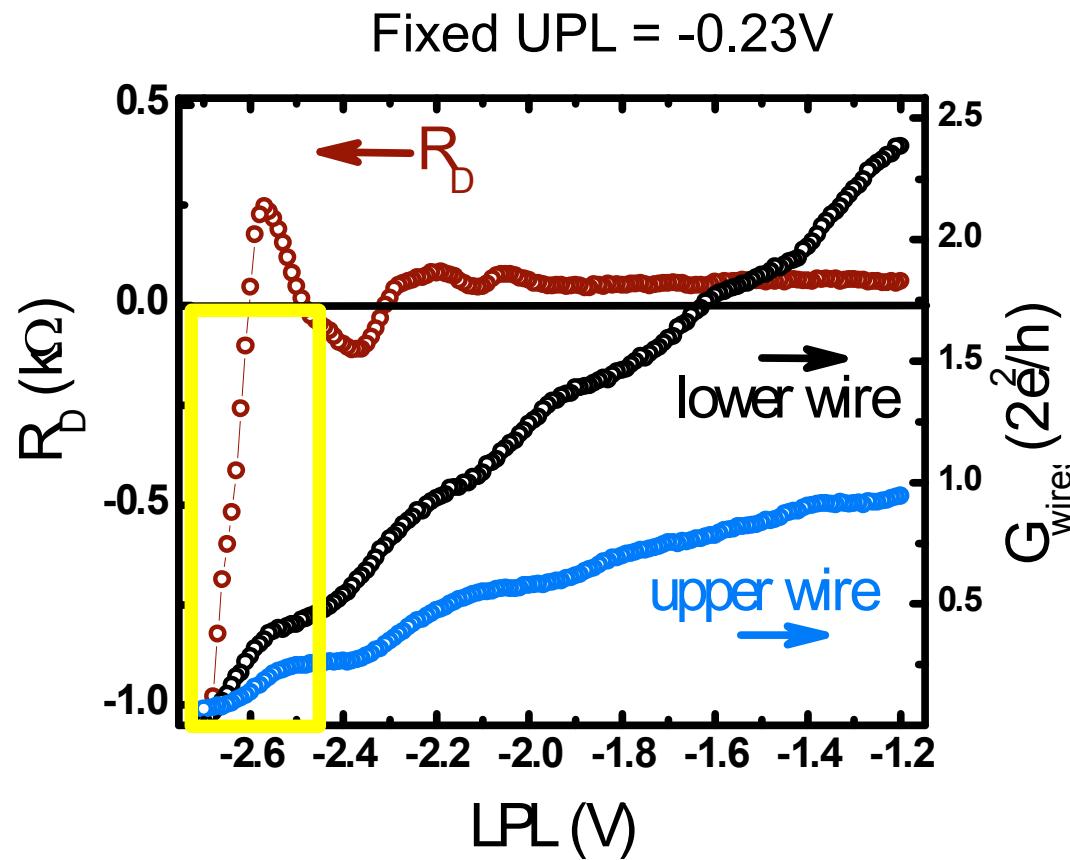
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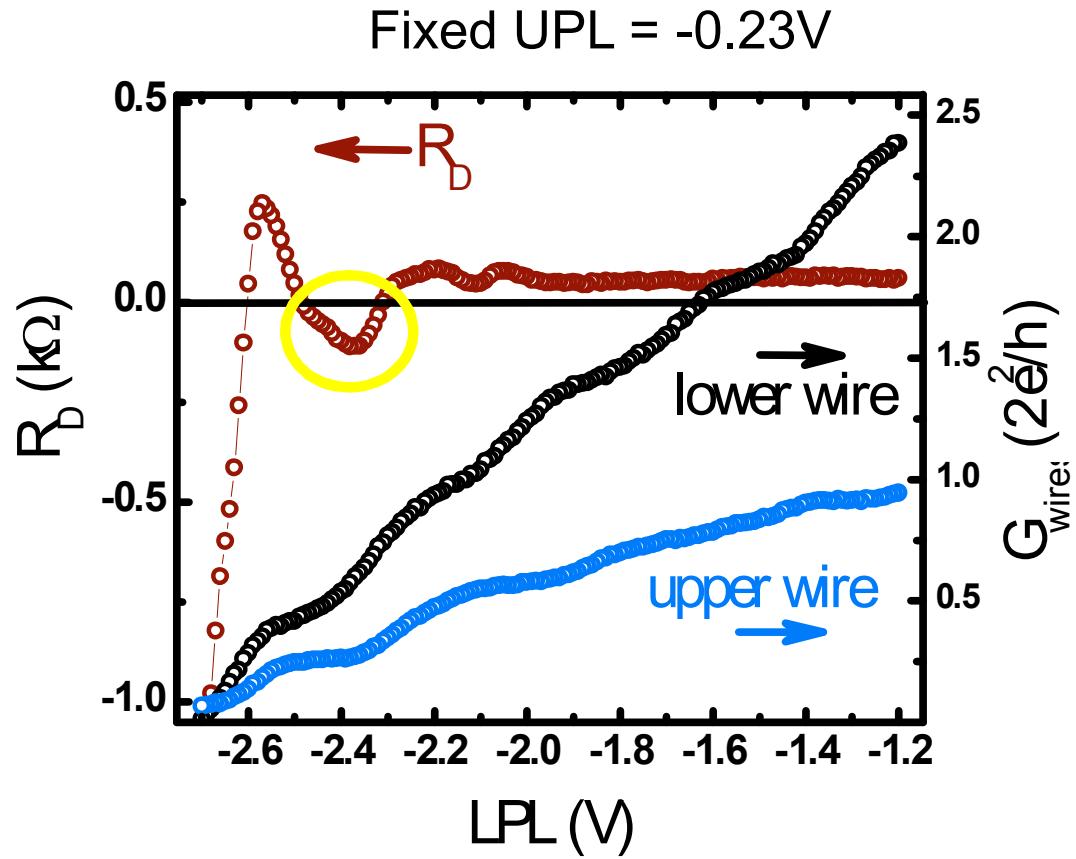


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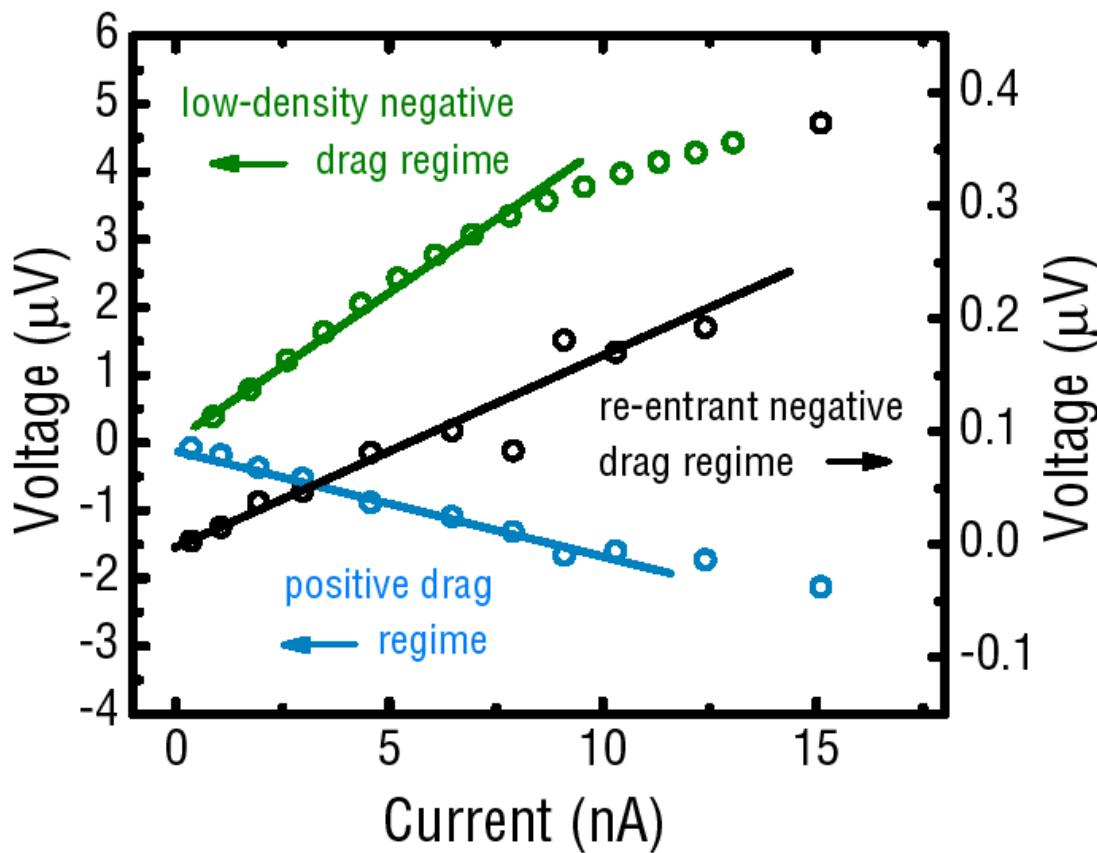
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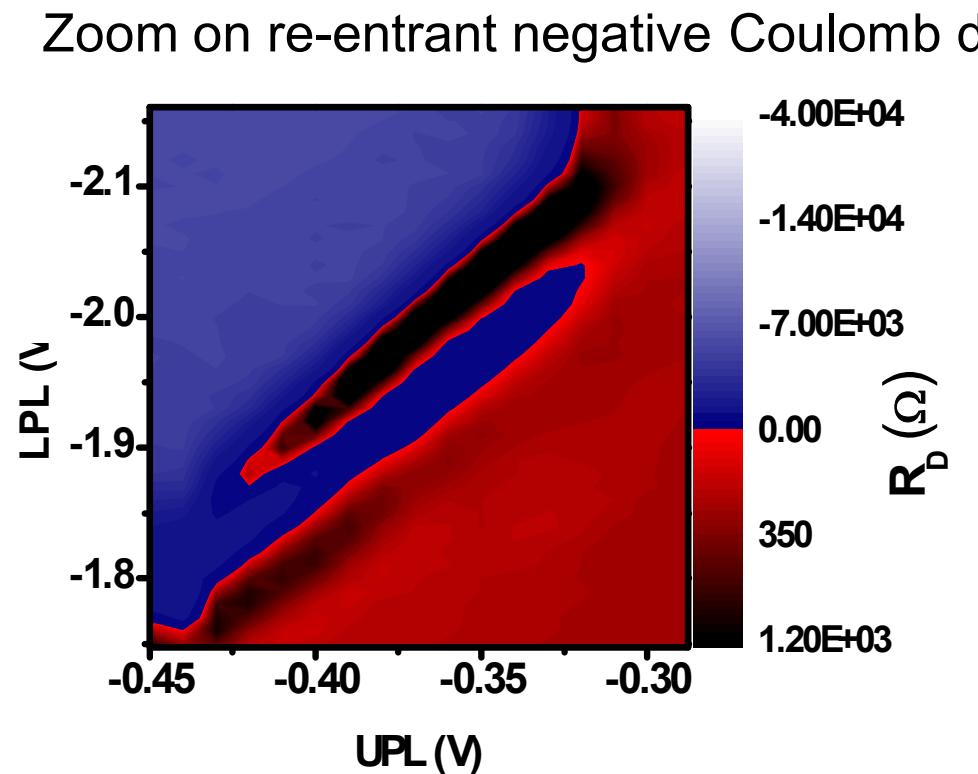
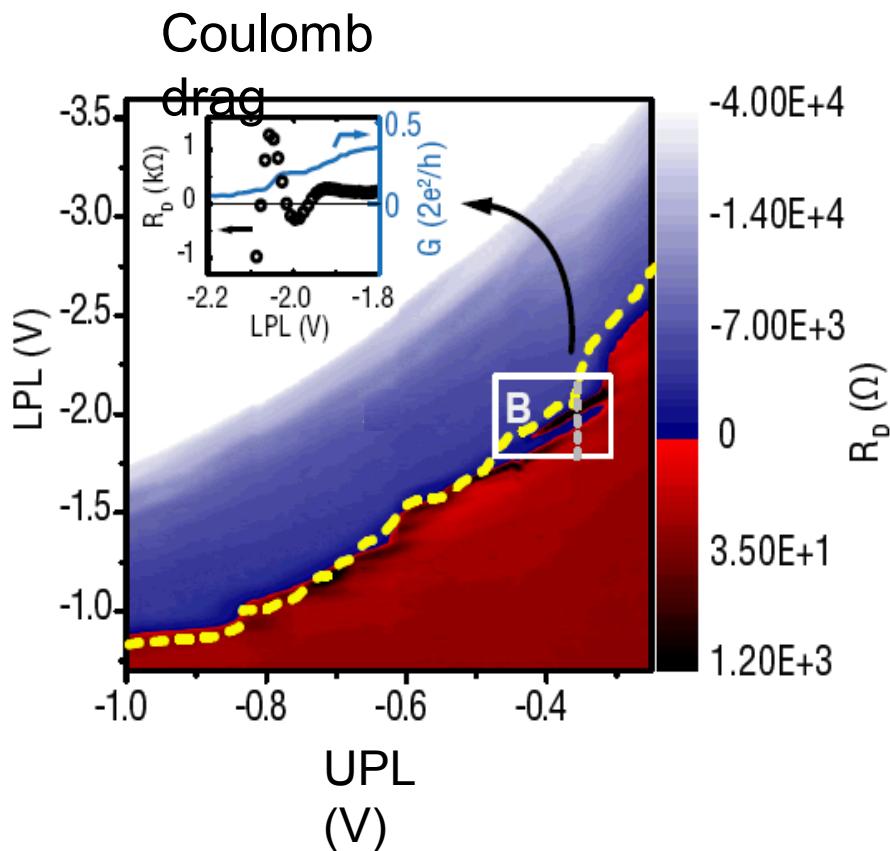


Consistency test for Coulomb drag



- Linear with drive current
- Drag resistance is independent of frequency
- No DC response is measured in the drag wire while sending an AC drive current

Mapping of the Coulomb drag



- Features in the drag signal can be tracked over large range of gate voltages
- Line up with subband occupancy mapping of the wires



Interpretation of re-entrant negative drag

- Low-density negative drag : heuristically attributed to Wigner crystallization
 - Re-entrant negative drag occurs at density too high for typical Wigner crystallization
- Possible explanations :
 - Gate-dependent enhancement of electron-hole asymmetry coupled with non-monotonic increase in transmission probability of electrons along wire.¹
 - Local hole-like dispersion relation in the quantum wires band structure



Conclusion and future plans

First vertically coupled quantum wires with :

- Independent control over subbands occupancy
- Independent contacts to each wire

Coulomb drag measurements

- Study drag with multiple 1D subbands regime
- Reproduce qualitatively other 1D drag experiments
- Observe a new re-entrant negative drag regime at high density

Future plans

- Measure temperature dependence of Coulomb drag in vertical structures
- Measure Coulomb drag in devices with a smaller interwire separation

General Coulomb drag measurements

Measured quantity : transresistance

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